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H/Pat Andra
9-26-02
PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Reissue Patent Application:

Applicants : Trung T. Doan and Gurtej S. Sandhu
Assignee: Micron Technology, Inc.
Filed : December 19, 2001
For : POLISHING PAD REFURBISHER FOR IN SITU, REAL-TIME CONDITIONING
AND CLEANING OF A POLISHING PAD USED IN CHEMICAL-MECHANICAL
POLISHING OF MICROELECTRONIC SUBSTRATES
Docket No. : 500300.02

Corresponding Issued U.S. Patent:

Patent No. : 6,004,196
Issued : December 21, 1999
Application No. : 09/032,230
Filing Date : February 27, 1998
Examiner : William Hong
Art Unit : 3725

BOX REISSUE
Commissioner for Patents
Washington, D.C. 20231

PRELIMINARY AMENDMENT

Sir:

Please accept the request for a reissue of U.S. Patent No. 6,004,196, filed herewith. Prior to conducting the examination of the reissue claims, please amend the reissue application as follows:

Please add the following new claims 31-53: